



(12) **CORRECTED EUROPEAN PATENT SPECIFICATION**

Note: Bibliography reflects the latest situation

(15) Correction information:
Corrected version no 1 (W1 B1)
INID code(s) 84

(51) Int Cl.7: **C23C 14/30**, C23C 14/50,
C23C 14/54, C23C 14/34,
C23C 16/40

(48) Corrigendum issued on:
13.07.2005 Bulletin 2005/28

(45) Date of publication and mention
of the grant of the patent:
04.05.2005 Bulletin 2005/18

(21) Application number: **01306852.3**

(22) Date of filing: **10.08.2001**

(54) **Apparatus and method for coating substrate**

Vorrichtung und Verfahren zur Substratbeschichtung

Appareil et procédé pour revêtir un substrat

(84) Designated Contracting States:
CH DE FR IT LI

(30) Priority: **11.08.2000 GB 0019848**

(43) Date of publication of application:
27.02.2002 Bulletin 2002/09

(60) Divisional application:
04076753.5

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